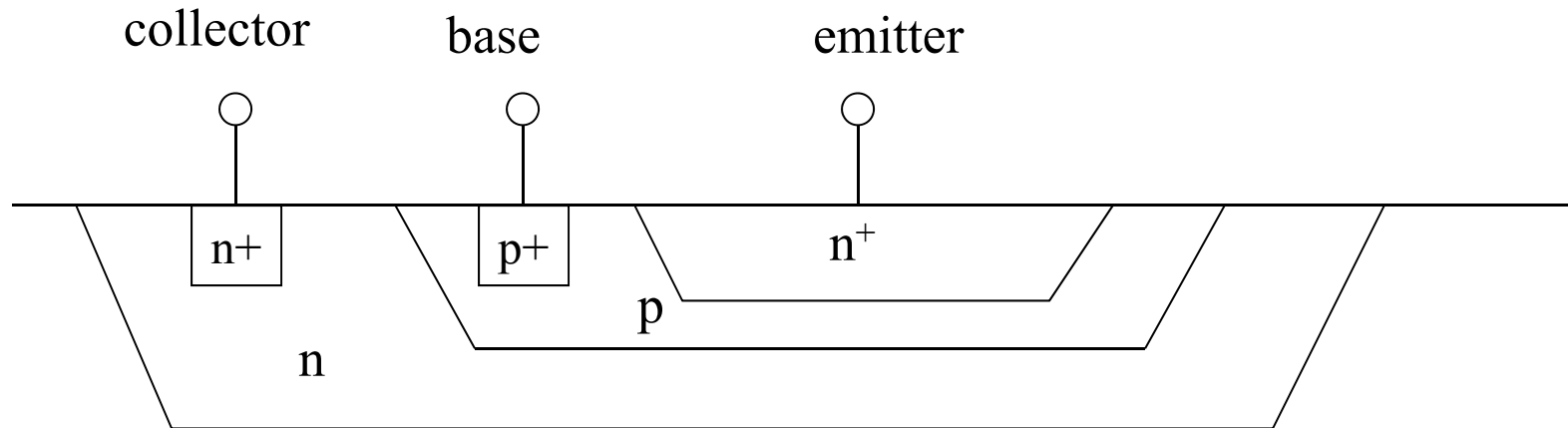


13. Bipolar transistors

Jan. 16, 2019

bipolar transistors

npn transistor



lightly doped p substrate

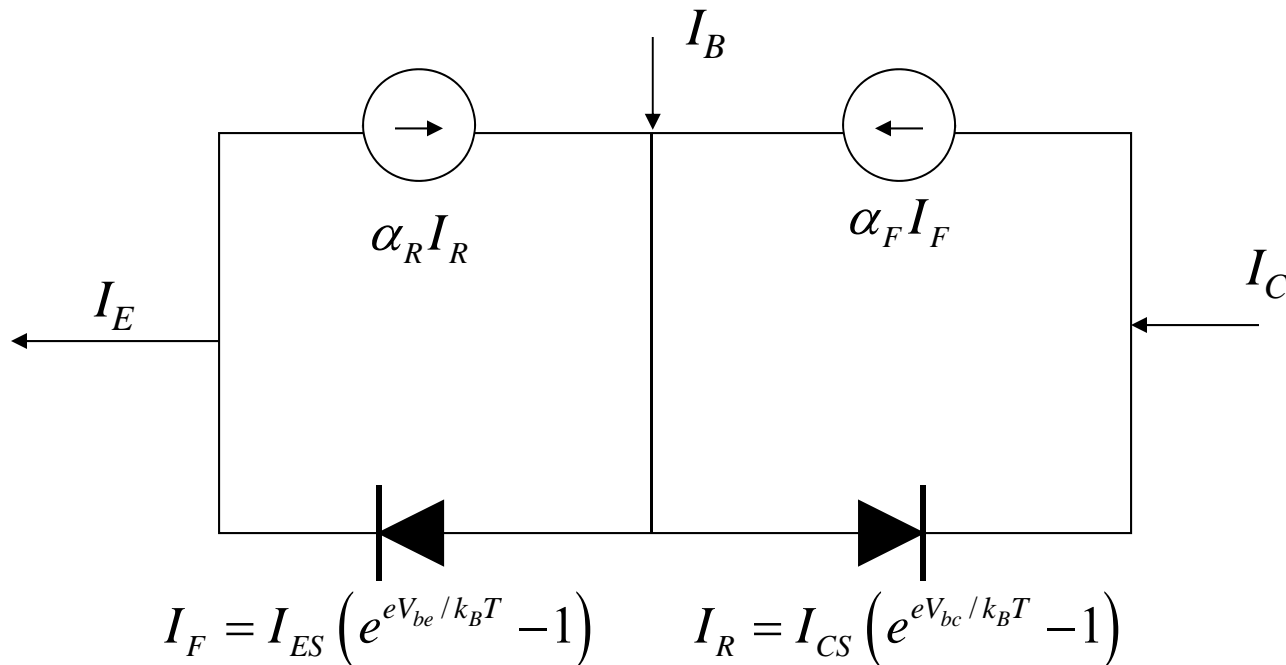
Used in front-end high-frequency receivers (mobile telephones), low input impedance amplifier.

Ebers-Moll model

$$I_E = I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - \alpha_R I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

$$I_C = \alpha_F I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

$$I_B = I_E - I_C$$

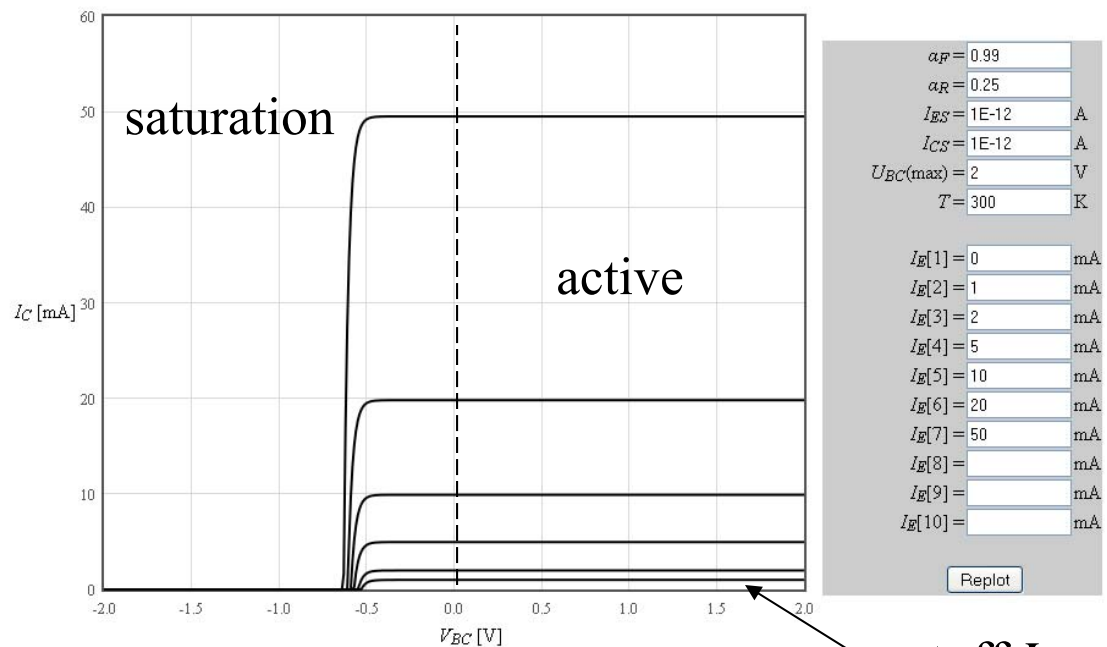
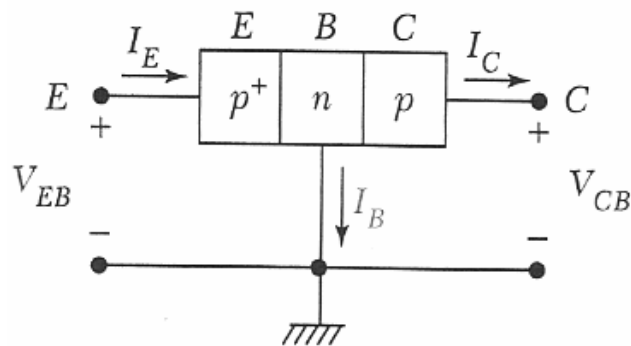


Common base configuration

$$I_E = I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - \alpha_R I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

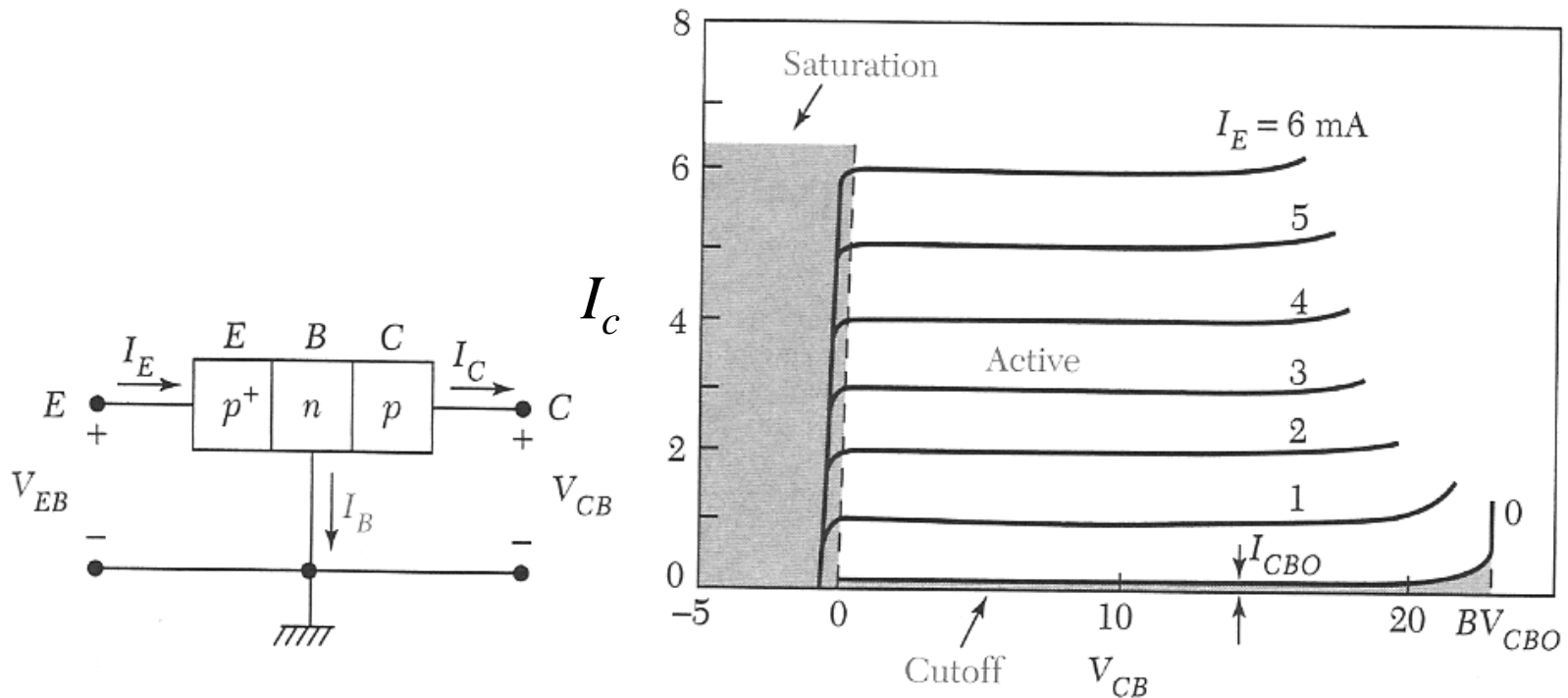
solve for V_{be}

$$I_c = \alpha_F I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$



cutoff $I_E < 0$

Common base configuration



$I_C \sim I_E$ buffer circuit: the output current is constant over a wide range of output voltages

Ebers - Moll Model

$$I_{ES} = \left[\frac{eA_{be}D_p p_{e0}}{W_{eb} - x_e} + \frac{eA_{be}D_n n_{b0}}{W_{bc} - W_{be}} \right]$$

$$\alpha_R I_{CS} = \frac{eA_{be}D_n n_{b0}}{W_{bc} - W_{be}}$$

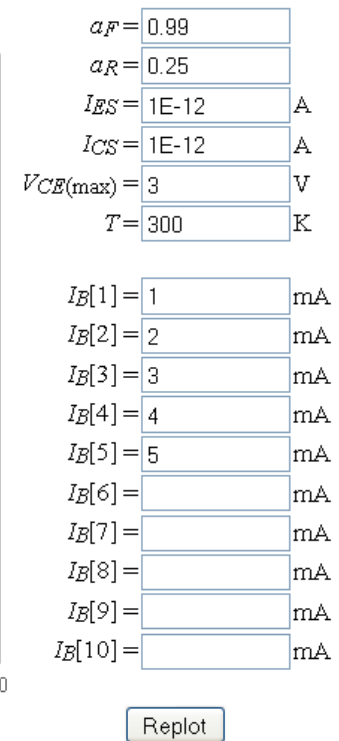
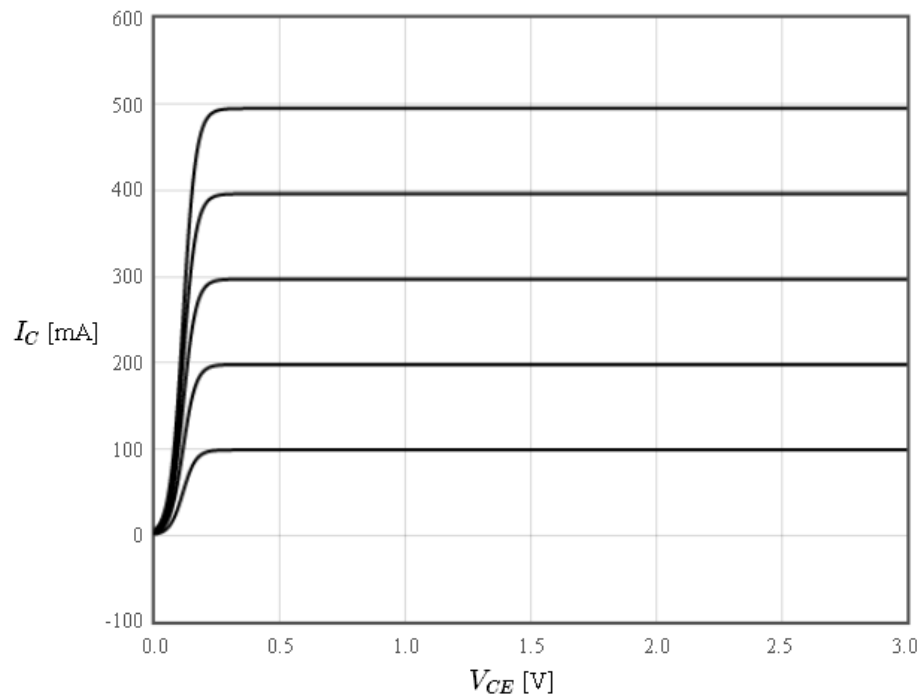
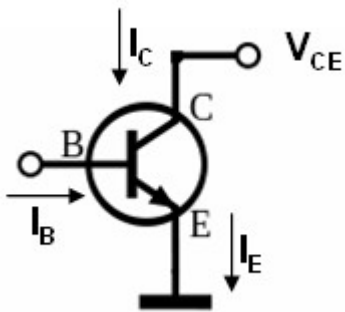
$$\alpha_F I_{ES} = \frac{eA_{bc}D_n n_{b0}}{W_{bc} - W_{be}}$$

$$I_{CS} = \left[\frac{eA_{bc}D_p p_{c0}}{x_c - W_c} + \frac{eA_{bc}D_n n_{b0}}{W_{bc} - W_{be}} \right]$$

Common emitter configuration

$$I_E = I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - \alpha_R I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right) \quad I_B = I_E - I_C$$

$$I_C = \alpha_F I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$



current amplification ~100

Current amplification factor

$$\beta = h_{fe} = \frac{I_C}{I_B}$$

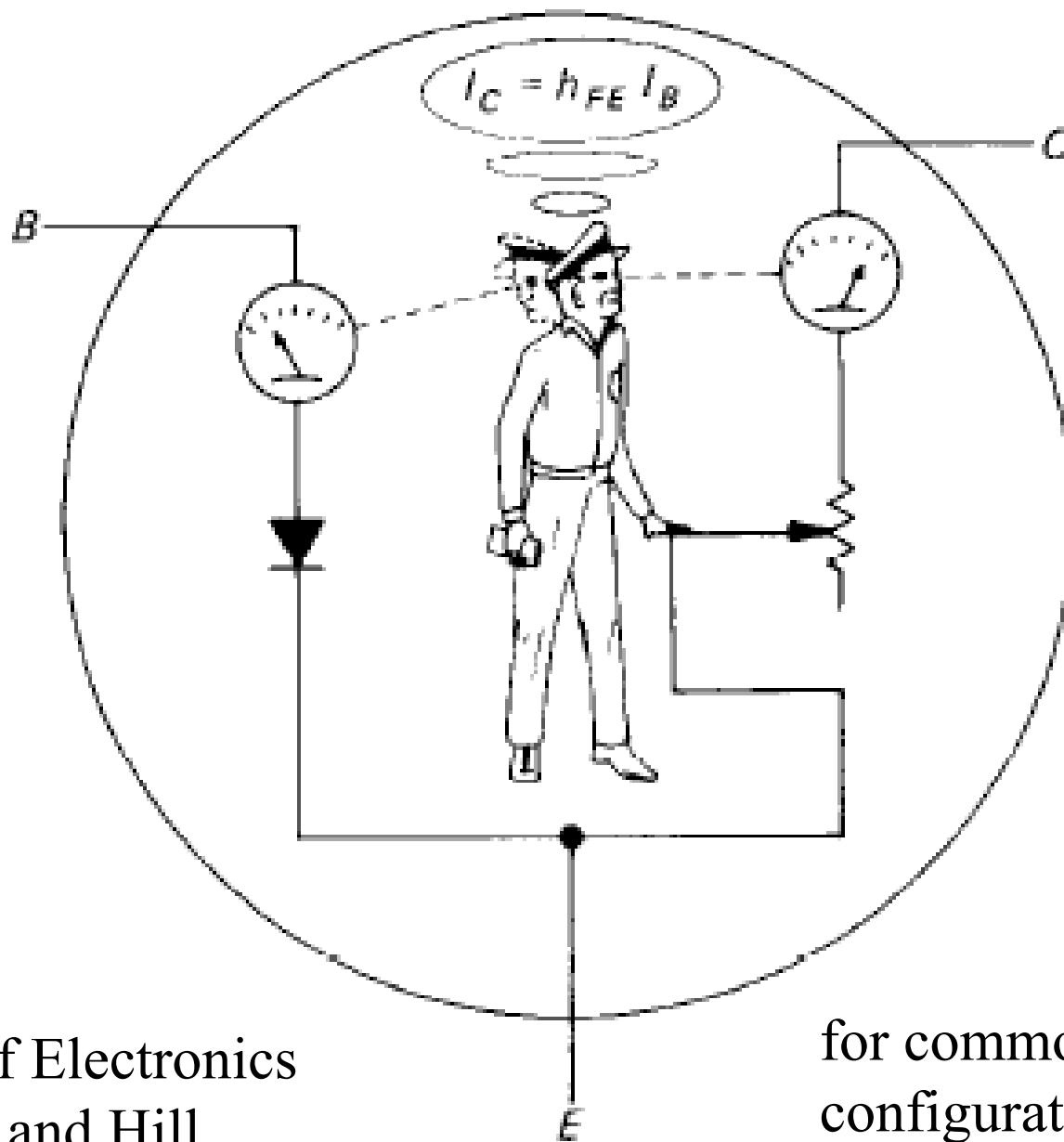
$$I_B = I_E - I_C$$

$$I_C = \alpha I_E$$

$$I_B = \left(\frac{1}{\alpha} - 1 \right) I_C$$

$$\beta = \frac{I_C}{I_B} = \frac{\alpha}{1 - \alpha} = \frac{B\gamma_e}{1 - B\gamma_e}$$

$$\beta \sim 50 - 500$$



The Art of Electronics
Horowitz and Hill

for common emitter
configuration

“Transistor man”

Transconductance

$$g_m = \frac{\partial I_C}{\partial V_{be}}$$

$$I_c = \alpha_F I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

The first term depends on V_{be}

$$g_m = \frac{e\alpha_F I_{ES}}{k_B T} e^{eV_{be}/k_B T} \approx \frac{eI_C}{k_B T} = \frac{e\beta I_B}{k_B T}$$

The transconductance can be very high.

Early effect

Ebers - Moll:

$$I_E = I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - \alpha_R I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

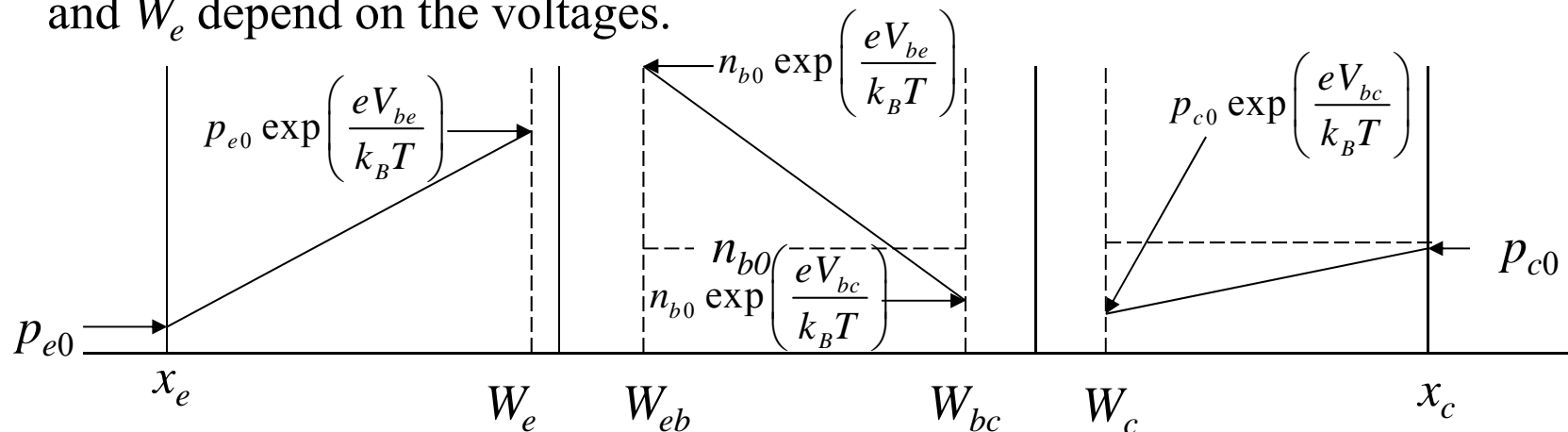
$$I_C = \alpha_F I_{ES} \left(e^{eV_{be}/k_B T} - 1 \right) - I_{CS} \left(e^{eV_{bc}/k_B T} - 1 \right)$$

$$I_B = I_E - I_C$$

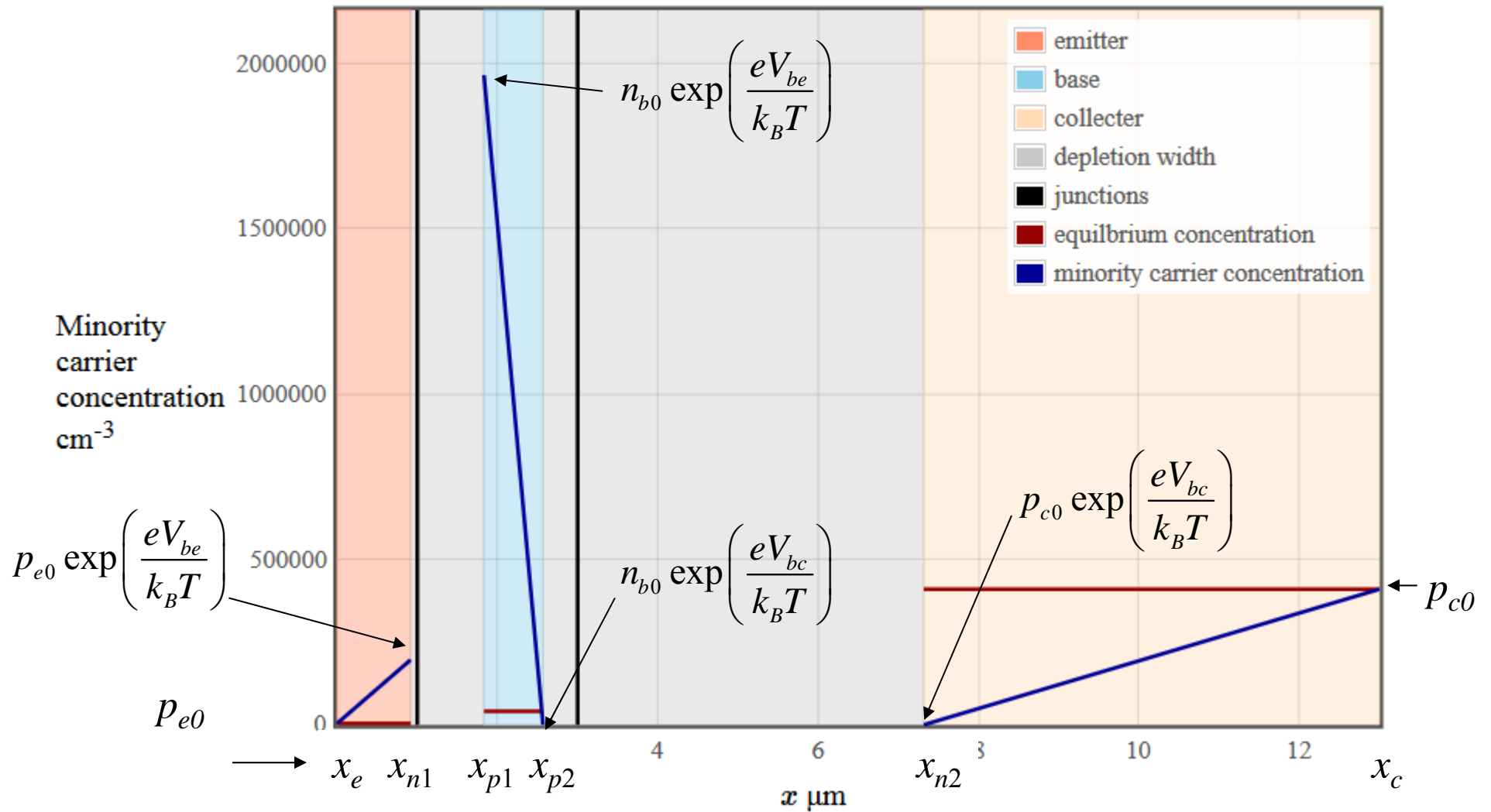
$$I_{ES} = \left[\frac{eA_{be} D_p p_{e0}}{W_{eb} - x_e} + \frac{eA_{be} D_n n_{b0}}{W_{bc} - W_{be}} \right]$$

$$I_{CS} = \left[\frac{eA_{bc} D_p p_{c0}}{x_c - W_c} + \frac{eA_{bc} D_n n_{b0}}{W_{bc} - W_{be}} \right]$$

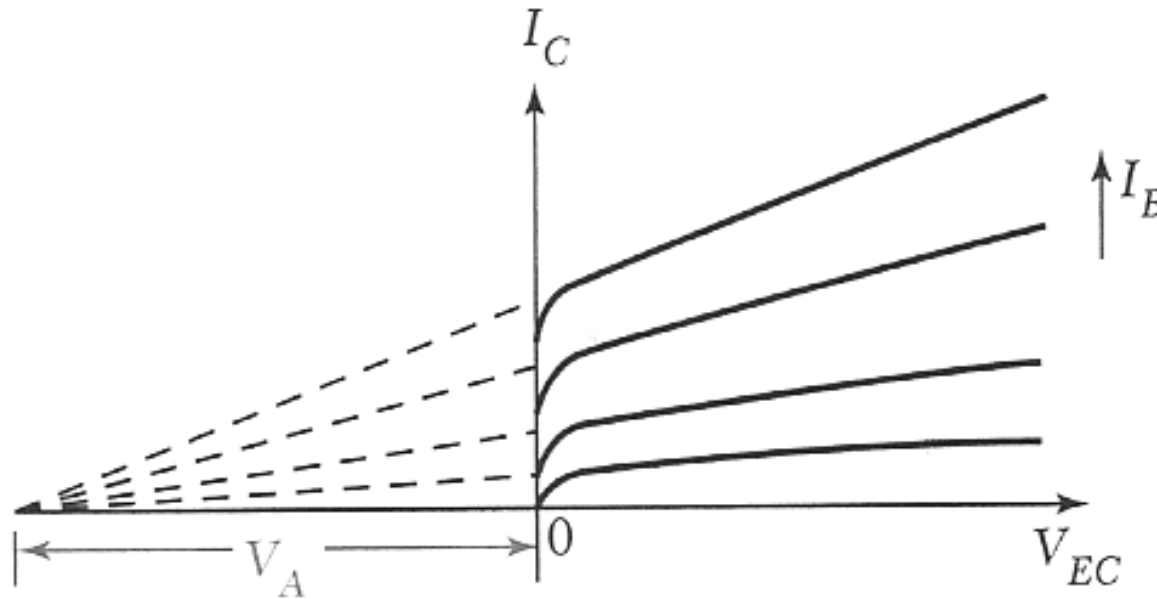
I_{ES} and I_{CS} are treated as constants but the depletion widths W_{bc} , W_{be} , W_c and W_e depend on the voltages.



Minority carrier concentration



Early effect



Common emitter configuration

Base width modulation: smaller width increases the diffusion current and increases the gain.

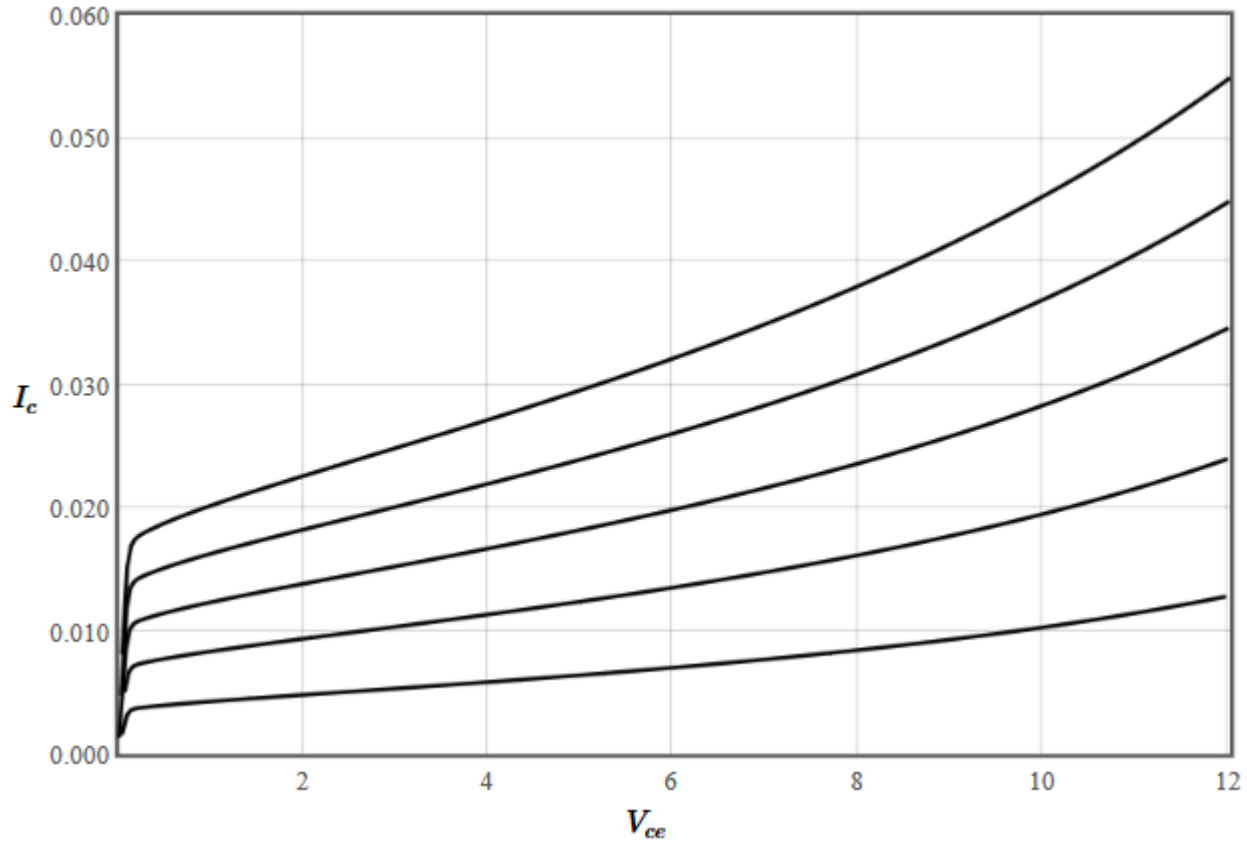
Punchthrough: The neutral base width goes to zero and all gain is lost.

Lightly dope the collector -> voltage drops in collector. Makes circuit slower.

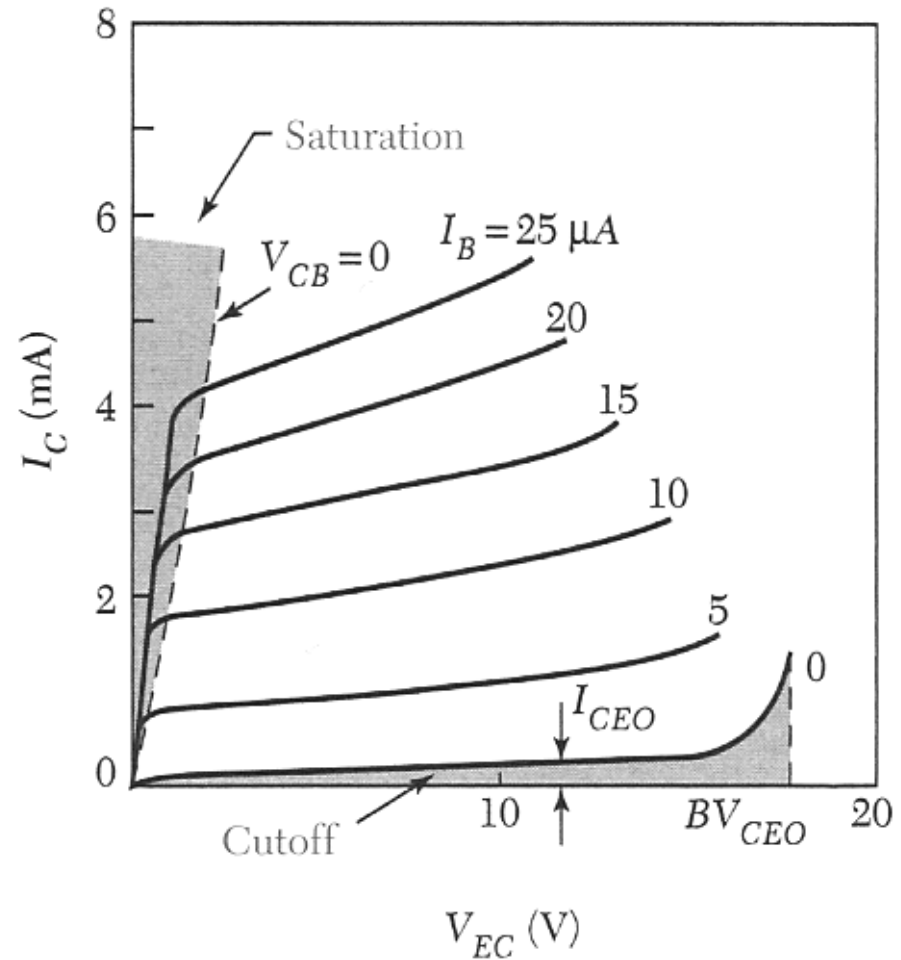
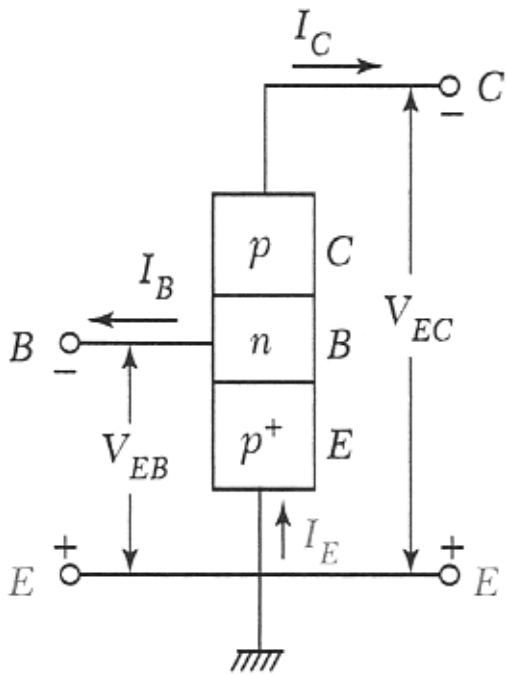
NPN common emitter configuration

n-Emitter		$A_{eb} = 1E-3$ cm ²
Minority $\mu_{pe} = 480$ cm ² /Vs	$N_{de} = 1E16$ cm ⁻³	$N_c(300K) = 2.78E19$ cm ⁻³
$\tau_{pe} = 1E-5$ s		$N_v(300K) = 9.84E18$ cm ⁻³
		$E_g = 1.166-4.73E-4*T*(T+636)$ eV
		$\epsilon_r = 11.9$
p-Base		$I_{bmax} = 0.001$ eV
Minority $\mu_{nb} = 1350$ cm ² /Vs	$N_{ab} = 1E15$ cm ⁻³	$V_{ce max} = 12$ eV
$\tau_{nb} = 1E-5$ s		$x_1 - x_e = 1$ μm
		$x_2 - x_1 = 2$ μm
		$x_c - x_2 = 10$ μm
n-Collector		$T = 300$ K
Minority $\mu_{pc} = 480$ cm ² /Vs	$N_{dc} = 1E14$ cm ⁻³	
$\tau_{pc} = 1E-5$ s		
<input type="button" value="Calculate"/>		

$$I_C \sim \beta I_B$$

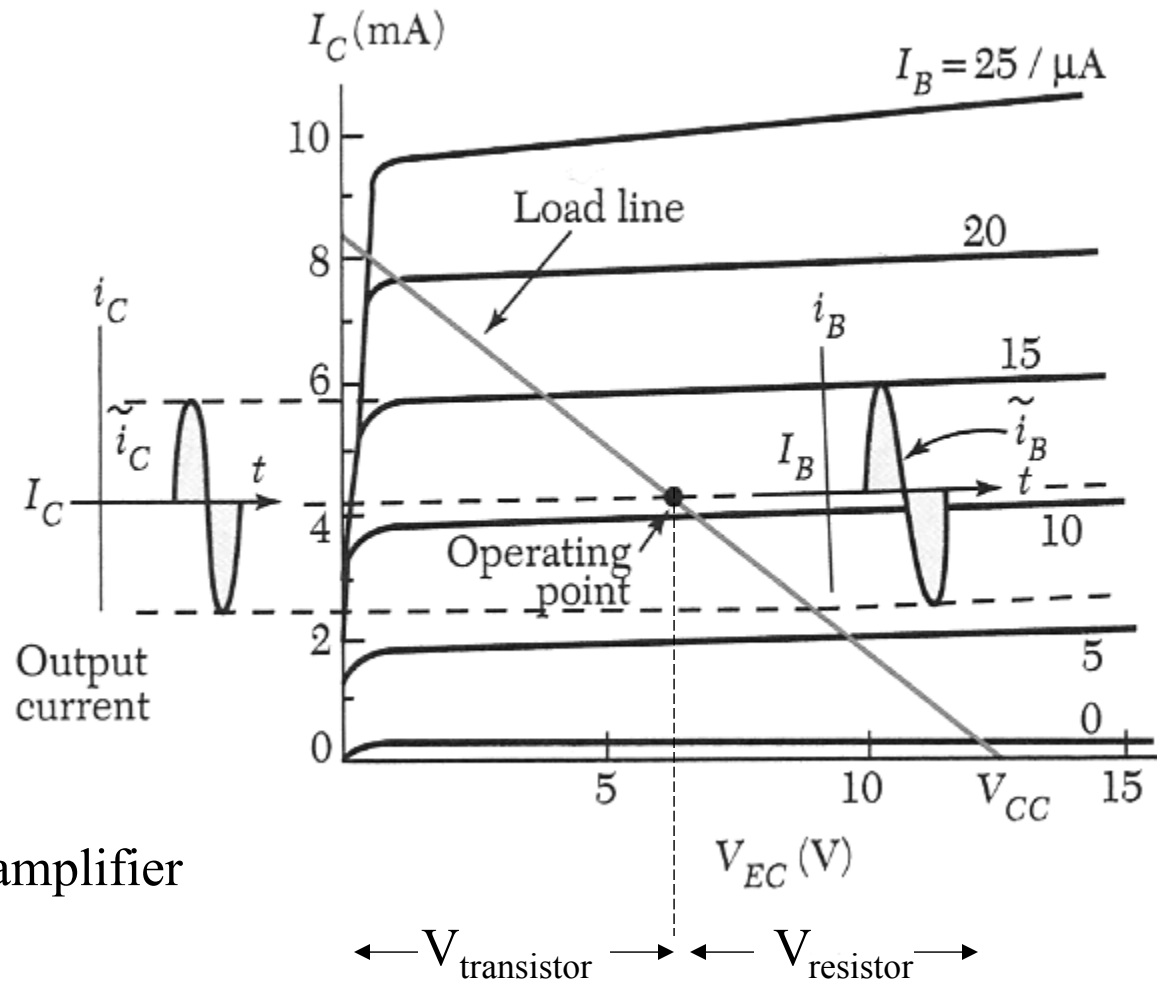
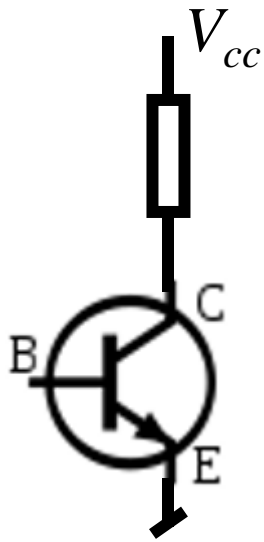


Common emitter configuration



$$I_C \sim \beta I_B \text{ amplifier}$$

Small signal response



Low input impedance amplifier

Small signal response

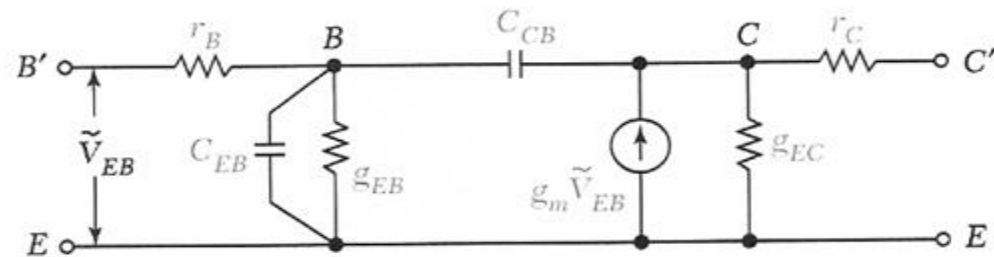
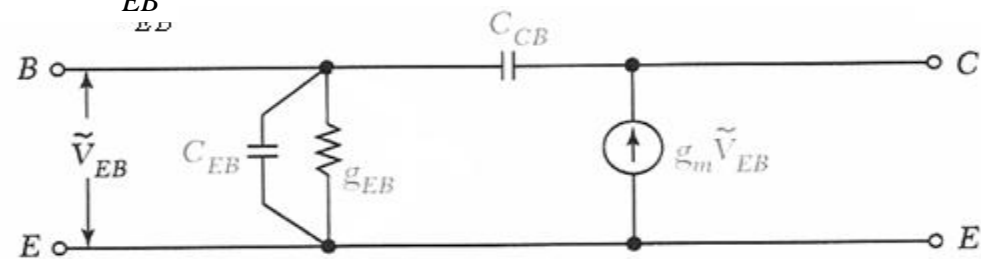
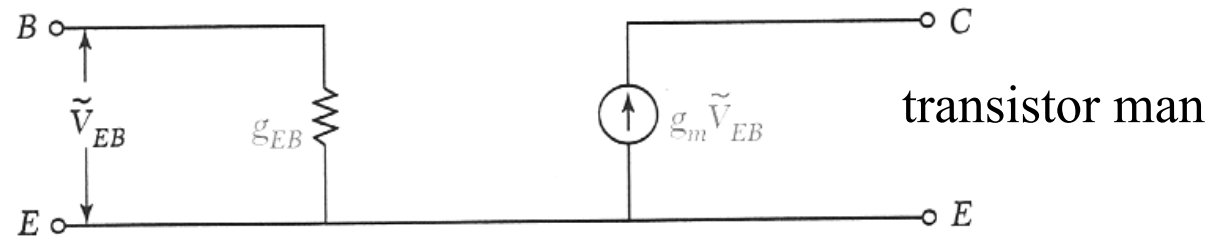
$$\tilde{i}_c = \beta \tilde{i}_B = \beta g_{EB} \tilde{v}_{EB}$$

input conductance:

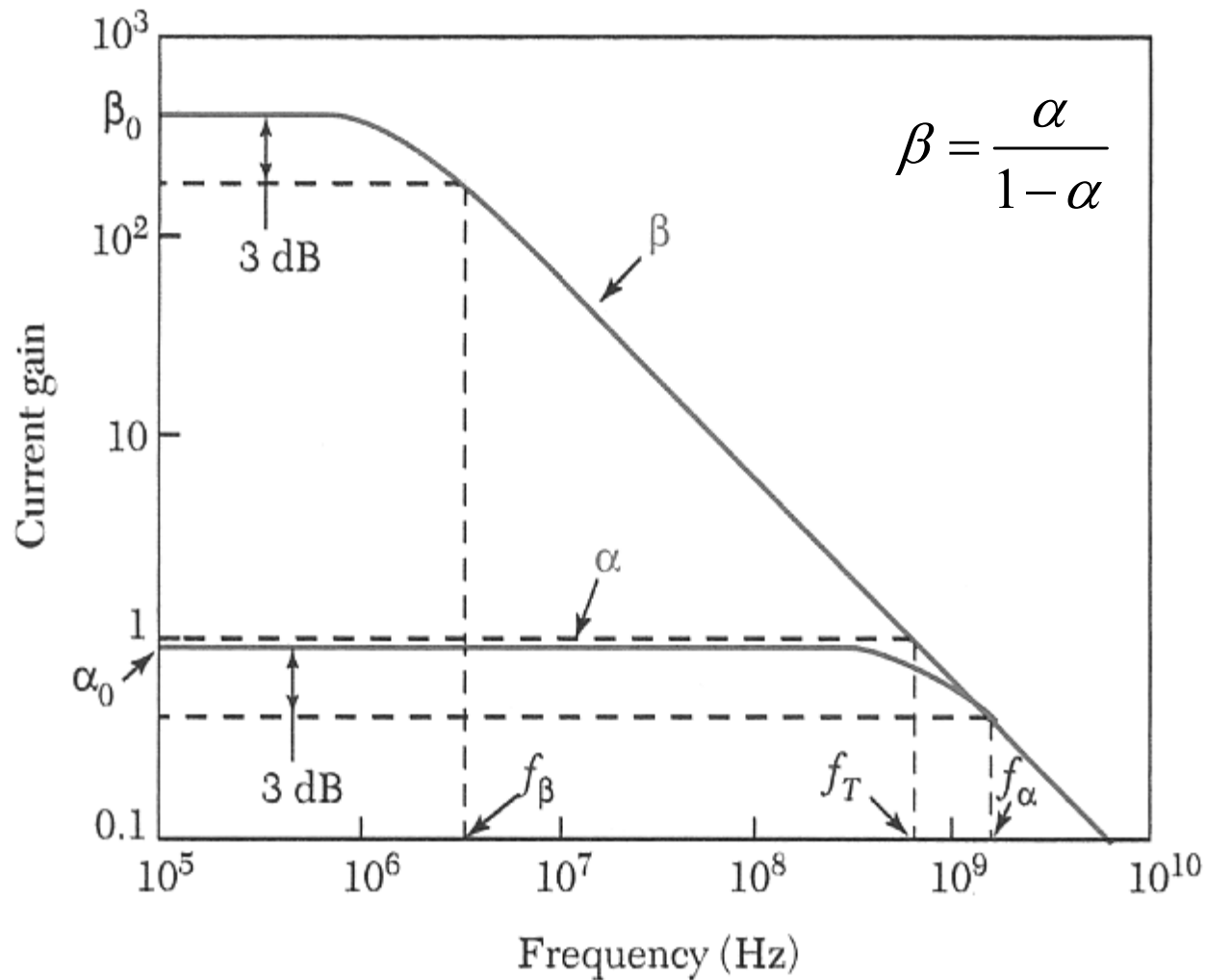
$$g_{EB} = \frac{\tilde{i}_B}{\tilde{v}_{EB}}$$

transconductance:

$$g_m = \frac{\tilde{i}_c}{\tilde{v}_{EB}}$$



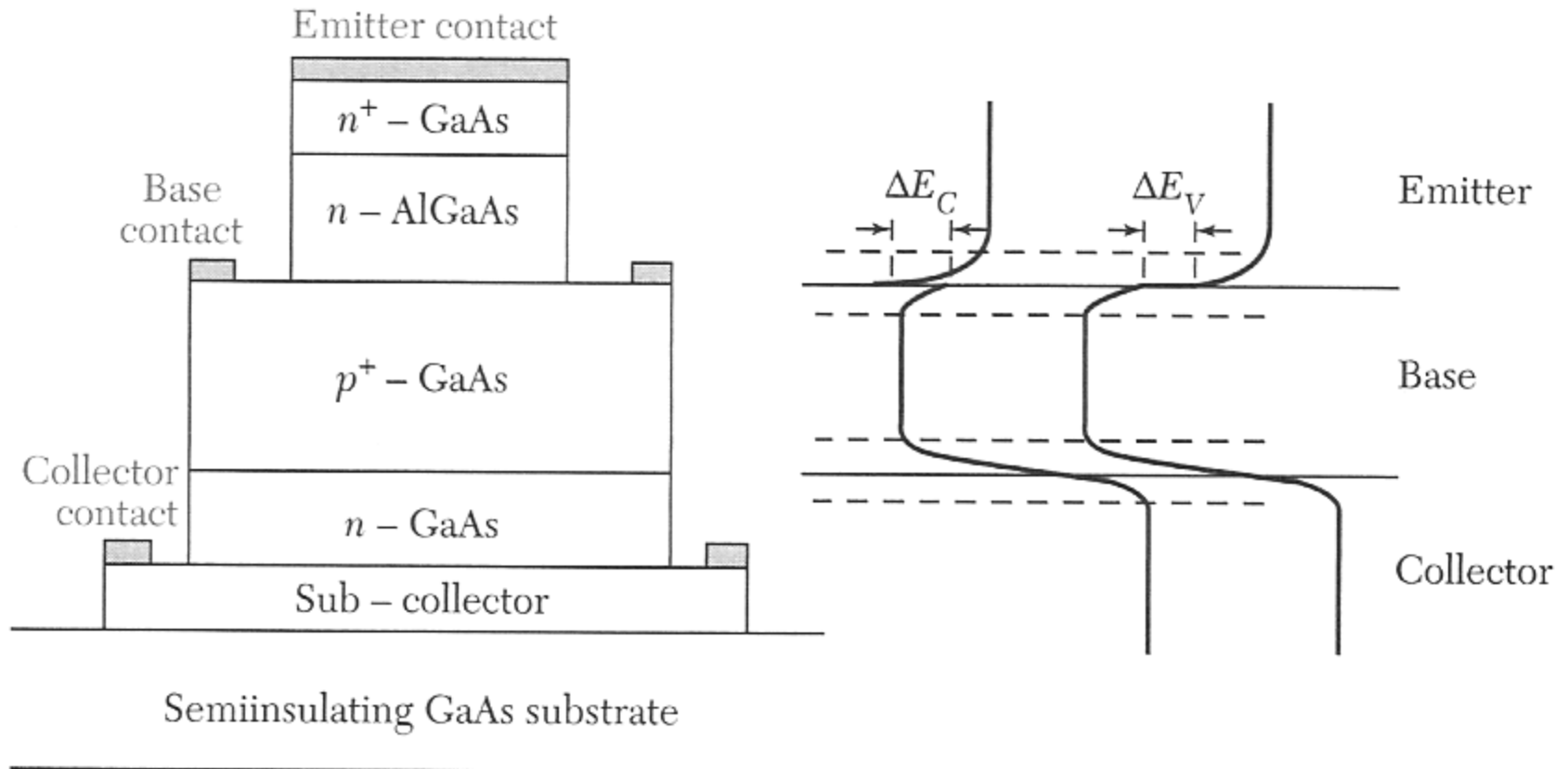
Small signal response



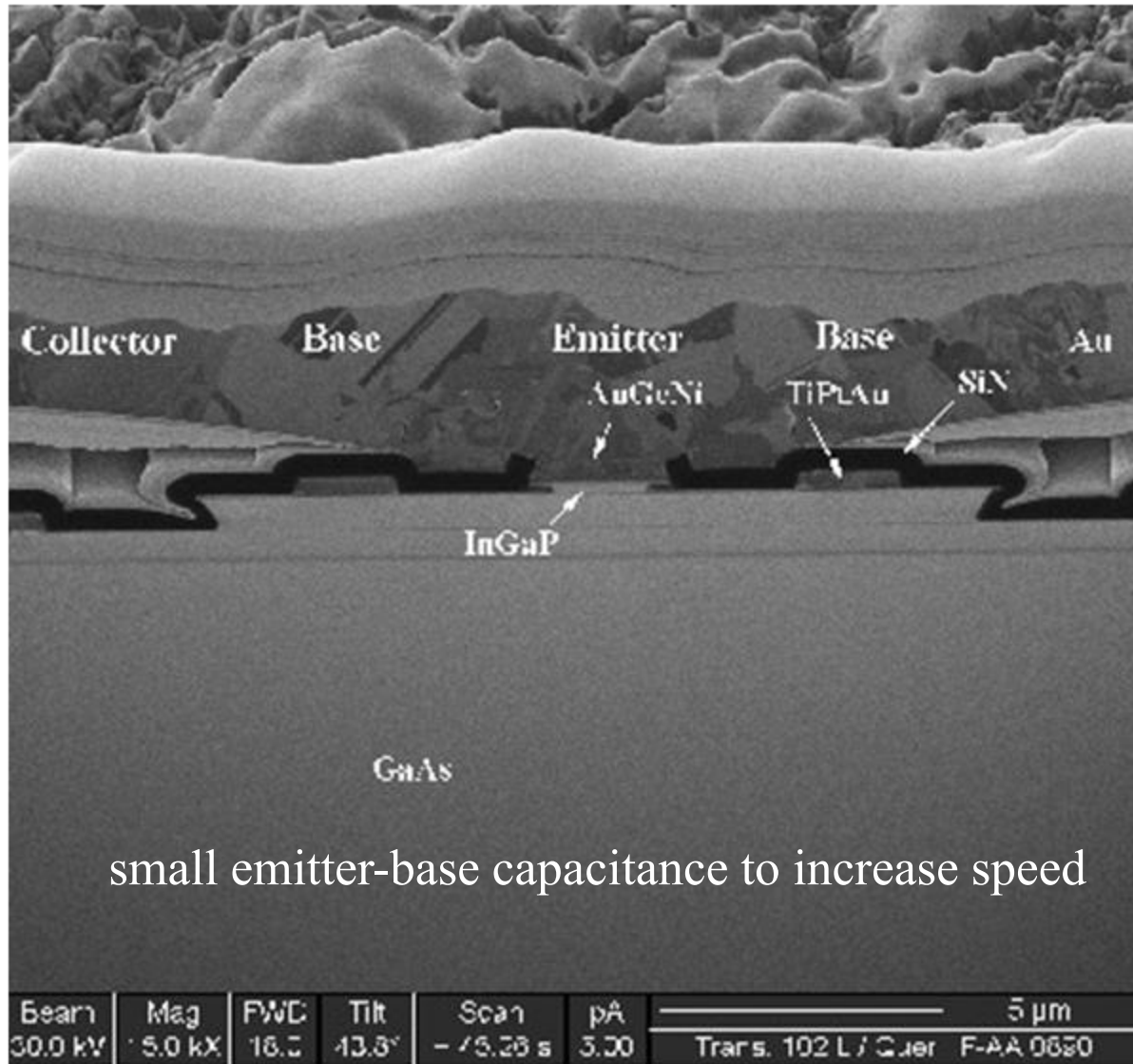
$$f_\beta = (1 - \alpha_0) f_\alpha$$

$$f_T = \alpha_0 f_\alpha$$

Heterojunction bipolar transistors



Heterojunction bipolar transistor



HBT current gain

$$I_C = \beta I_B$$

$$\beta = \frac{\alpha}{1-\alpha} \approx \frac{n_{B0}}{p_{E0}} \quad (\text{npn})$$

Higher doping in the emitter makes the minority carrier concentration lower in the emitter.

$$n_{B0} = \frac{n_i^2}{N_A} = \frac{N_C N_V \exp(-E_{gB} / k_B T)}{N_A}$$
$$p_{E0} = \frac{n_i^2}{N_D} = \frac{N'_C N'_V \exp(-E_{gE} / k_B T)}{N_D}$$

If the emitter and the base have different band gaps

$$\beta = \frac{N_E}{N_B} \frac{N_c N_v}{N'_c N'_v} \exp\left(\frac{\Delta E_g}{k_B T}\right) \sim 100000$$

HBT current gain

A HBT has an emitter bandgap of 1.62 and a base bandgap of 1.42.

A BJT has an emitter bandgap of 1.42 and a base bandgap of 1.42.

Both have an emitter doping of 10^{18} cm^{-3} and a base doping of 10^{15} cm^{-3} .

How much larger is the gain in the HBT?

$$\frac{\beta(\text{HBT})}{\beta(\text{BJT})} = \exp\left(\frac{\Delta E_g}{k_B T}\right) = \exp\left(\frac{1.62 - 1.42}{0.0259}\right) = 2257$$

HBT

Trade off gain for higher speed

Higher base doping

- lower base resistance

- reduced Early effect

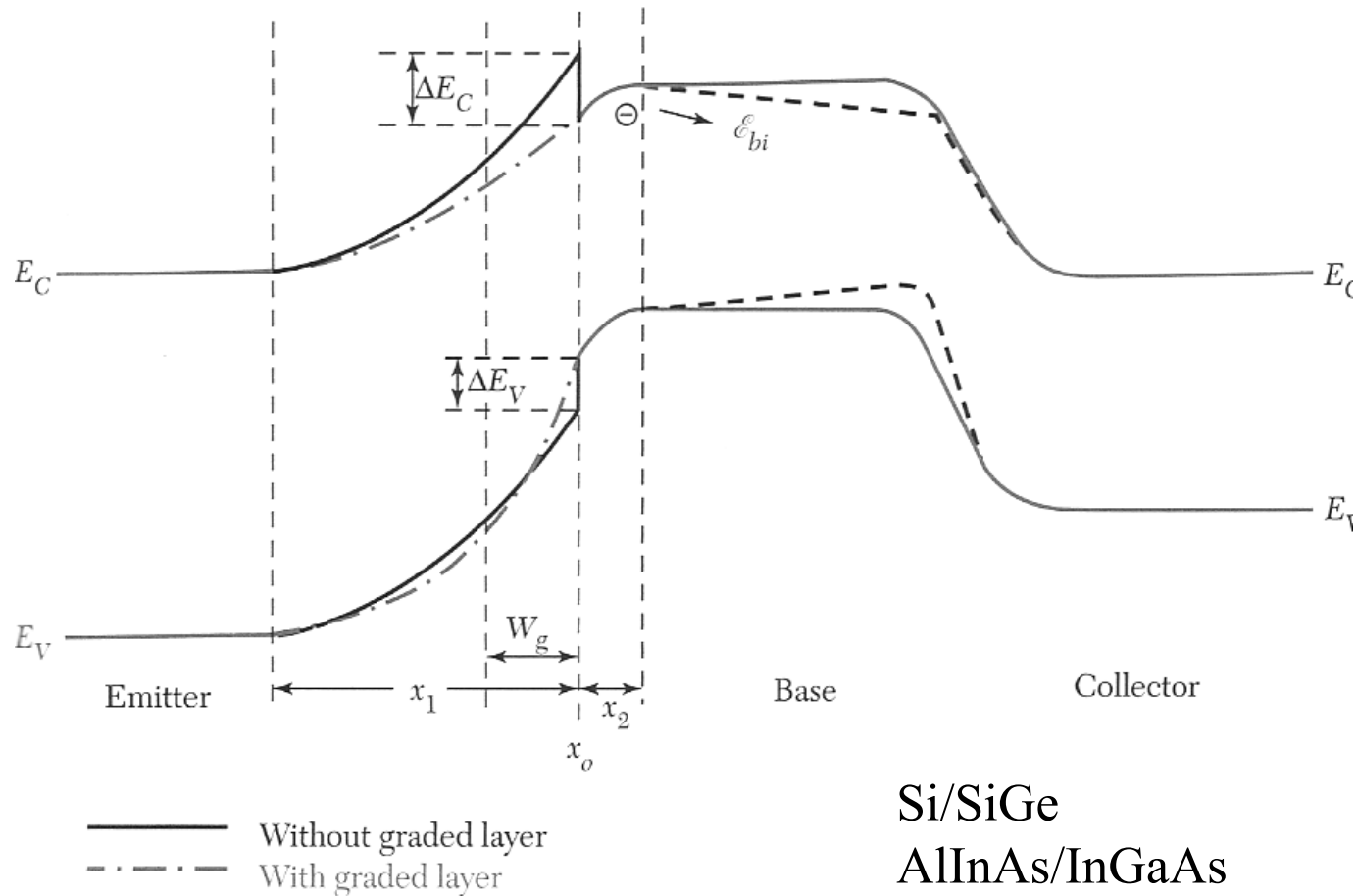
- less trouble with punch through

- base can be made thinner -> faster transistors

Because of higher base doping, a higher collector doping is possible without punch through

- lower collector resistance

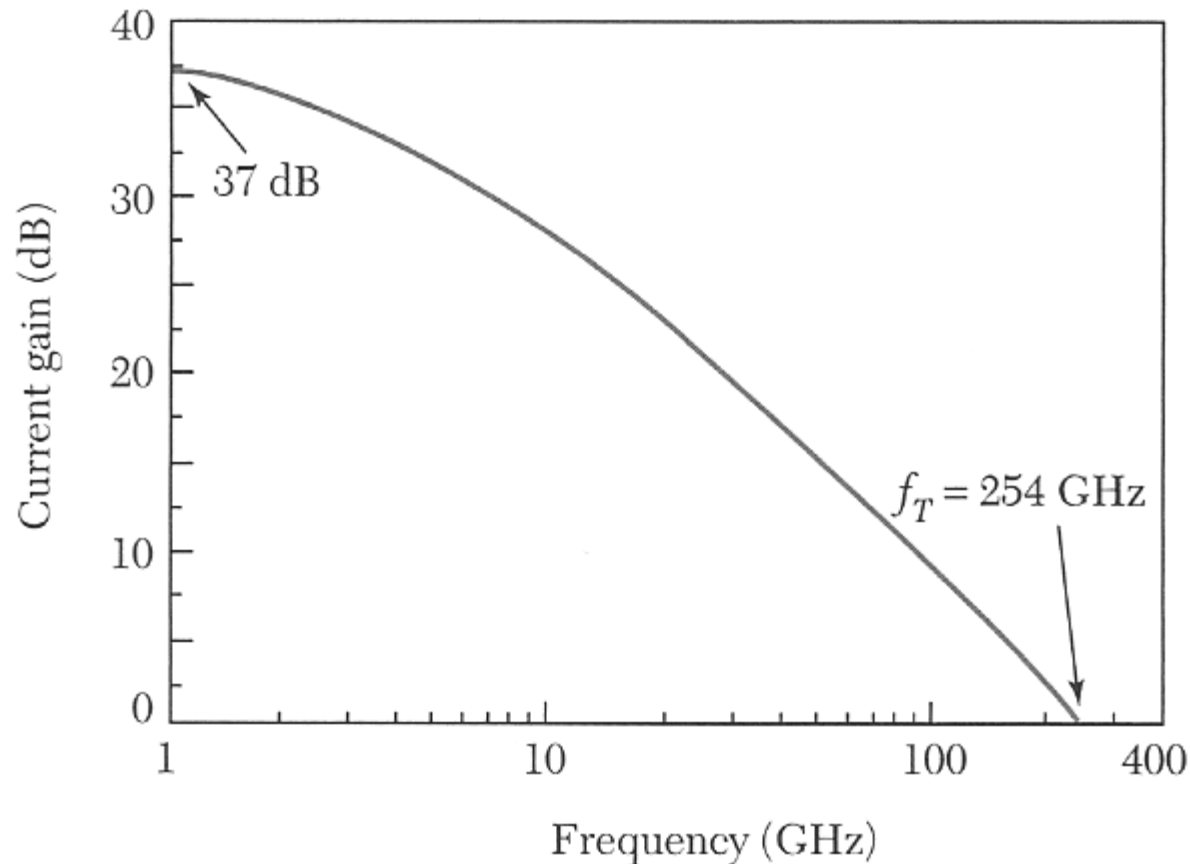
HBT current gain



band discontinuity reduces emitter efficiency

Graded layer emitter and base improve performance

Heterojunction bipolar transistors



Fastest InP/InGaAs HBT's have an f_T of 710 GHz.

Higher doping in the base allows for a thinner base without punch through and lower base resistance and thus higher frequency operation

Microwave engineering

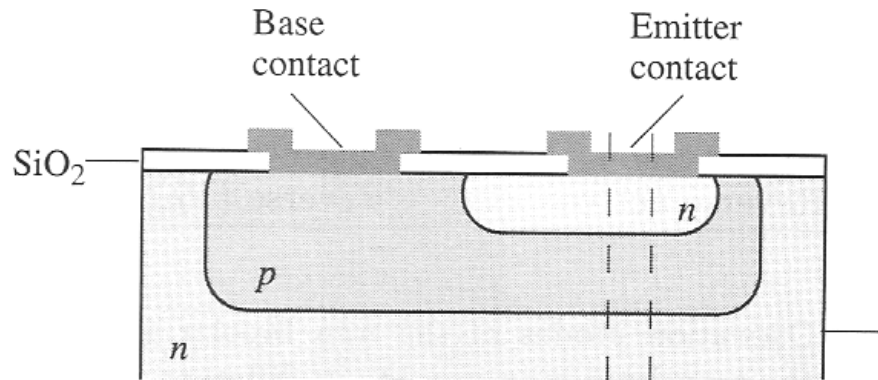
Electronics: $L \ll \lambda$ $f < \sim 10$ GHz

Microwave: $\lambda < L$ 10 GHz $< f < 1$ THz

TeraHertz: $\lambda \ll L$ 1 THz $< f < 100$ THz

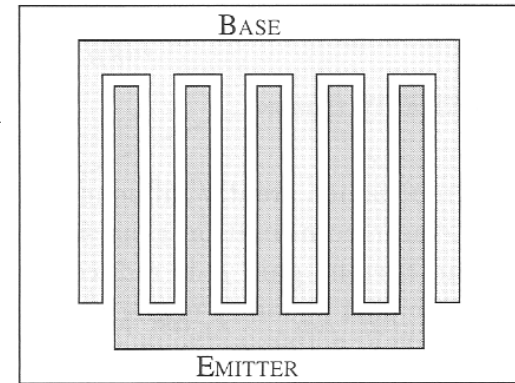
Optics: $\lambda \ll L$ 100 THz

Interdigitated contacts in power transistors

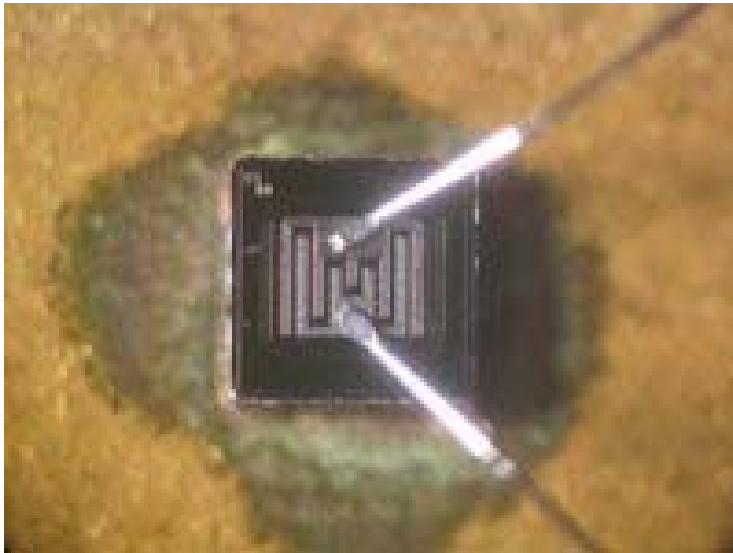
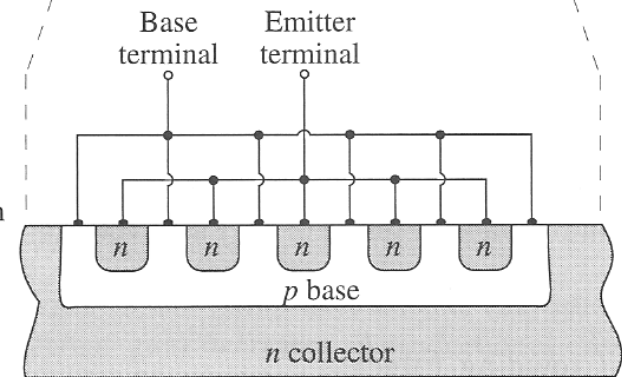


Interdigitated fingers to inject current uniformly into a bipolar device

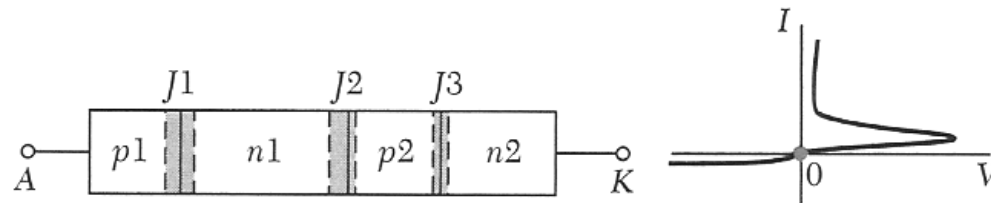
Top view



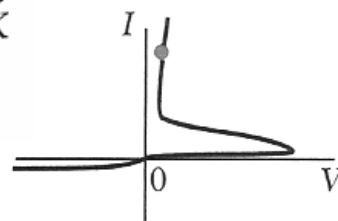
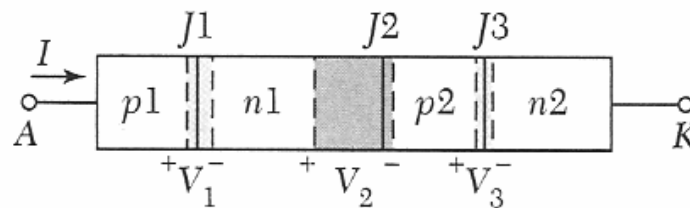
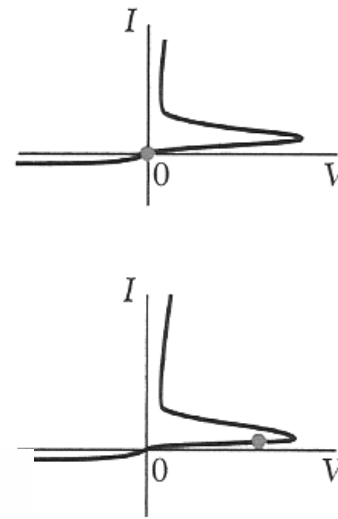
Cross-section



Thyristors

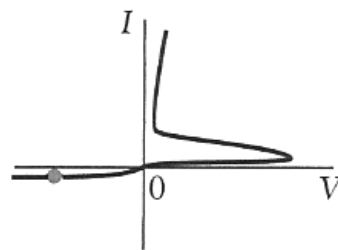
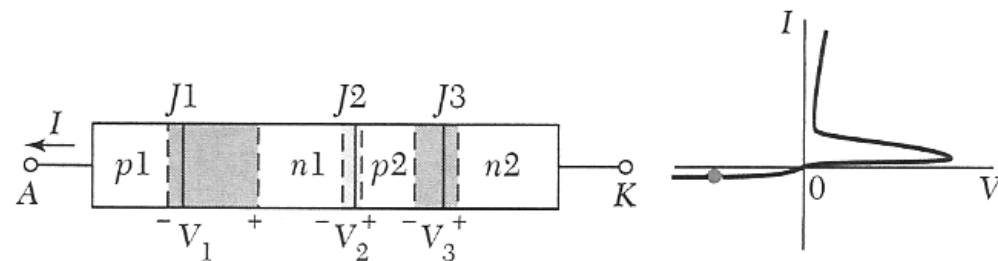


Forward blocking

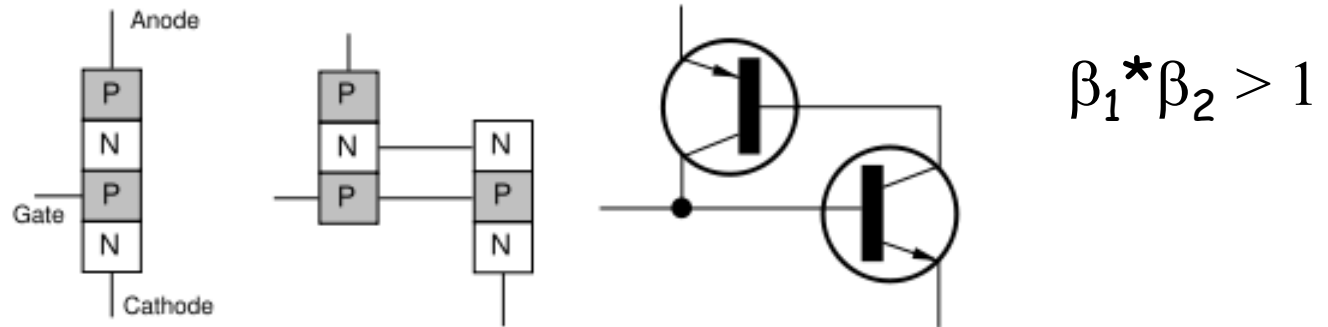


Forward conducting

Reverse blocking



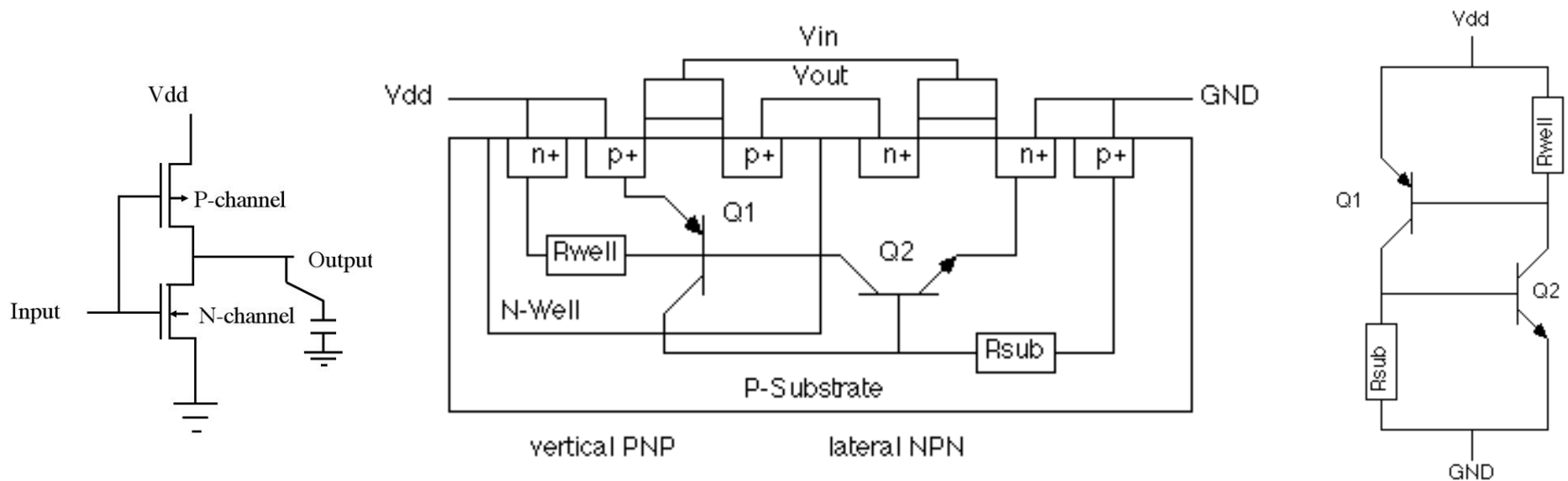
Thyristors



Used for switching high currents or voltages



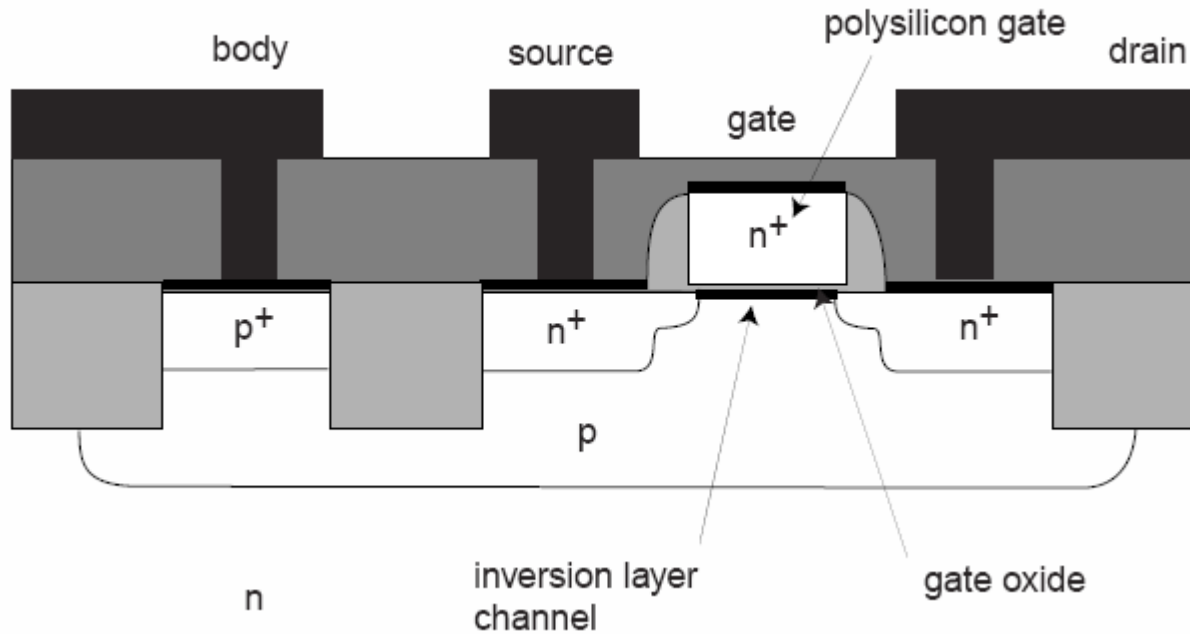
Latch-up



Both BJT's conduct, creating a low resistance path between V_{dd} and GND. The product of the gains of the two transistors in the feedback loop, is greater than one. The result of latchup is at the minimum a circuit malfunction, and in the worst case, the destruction of the device.

<http://www.ece.drexel.edu/courses/ECE-E431/latch-up/latch-up.html>

Subthreshold current



If the p-concentration in the channel is low, electrons emitted into the channel by the forward biased junction diffuse across the channel without recombining.